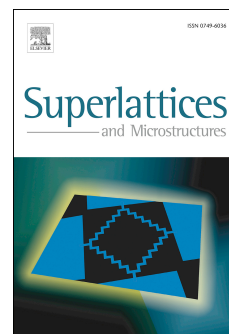


# Accepted Manuscript

Effect of sputtering deposition process of indium tin oxynitride on surface damage of gallium nitride film

Lifei Tian, Guoan Cheng, Ruiting Zheng, Kun Tian, Xiaolu Yan, Zhengguang Hu, Hougong Wang



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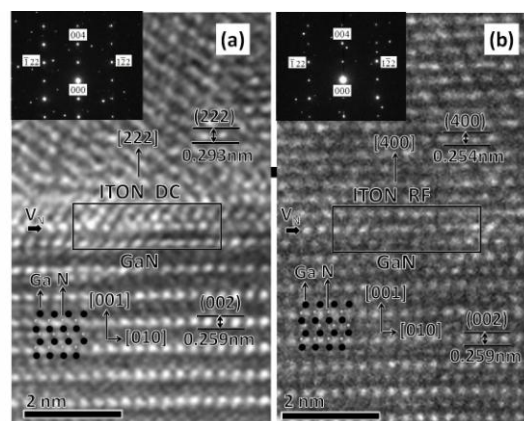
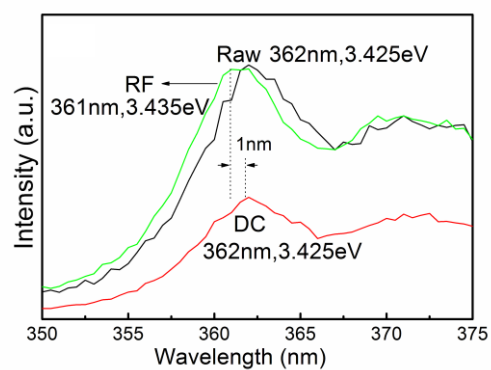
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